

APW



PATENT  
Attorney Docket No. 01197.0276-00

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

|                             |   |                               |
|-----------------------------|---|-------------------------------|
| In re Application of:       | ) |                               |
|                             | ) |                               |
| Hiroshi YAMADA et al.       | ) | Group Art Unit: 1795          |
|                             | ) |                               |
| Application No.: 10/587,315 | ) | Examiner: Vaughan II, Juan E. |
|                             | ) |                               |
| Filed: July 26, 2006        | ) |                               |
|                             | ) |                               |
| For: PHOTSENSITIVE RESIN    | ) | Confirmation No.: 4548        |
| COMPOSITION FOR LASER       | ) |                               |
| ENGRAVABLE PRINTING         | ) |                               |
| SUBSTRATE (as amended)      | ) |                               |

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

**SUPPLEMENTAL AMENDMENT**

Please amend this application to correct an error in the amendment filed

August 21, 2008:

**Amendments to the Claims** are reflected in the listing of claims in this paper.

**Remarks** follow the amendment sections of this paper.